



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application No. : 09/982,855 Confirmation No. 7689  
Applicant : Richard A. Metzler  
Filed : 10/22/2001  
TC/A.U. : 2813  
Examiner : Yennhu B. Huynh  
Title : Sidewalls As Semiconductor Etch Stop and  
Diffusion Barrier  
  
Docket No. : 5802P018X  
Customer No. : 8791

Commissioner for Patents  
PO Box 1450  
Alexandria VA 22313-1450

**AMENDMENT AND RESPONSE TO OFFICE ACTION**

Dear Sir:

In response to the Office action mailed on 12/15/2003,  
please enter the following amendments and remarks in the above-  
identified application as follows:

DRAWING amendments begin on page 2.

SPECIFICATION amendments begin on page 3.

CLAIM amendments begin on page 5.

REMARKS begin on page 18.

CONCLUSION and signature is on page 25.

APPENDIX I of 1 clean drawing sheet is attached hereto  
following page 25.

APPENDIX II of 1 annotated drawing sheet of the amended  
figures is attached hereto following Appendix I.